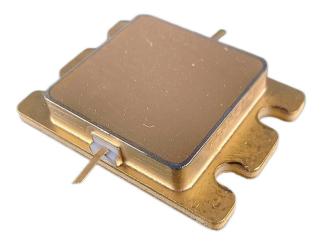


MCNI1214-P51 L-Band Internally Matched GaN Device

Key Features

- Operating Frequency: 1.20–1.40 GHz
- Saturated Output Power (Psat): ≥51.0dBm
- Power Gain(Gp): ≥13.0 dB
- Work Efficiency (η): ≥50%
- Port Matching: Zin/Zout = 50 Ω



Product Description

The MCNI1214-P51 is an internal matching GaN device, which adopts advanced co-planar internal matching MCM and thin film circuit technology. The typical working frequency range is 1.20–1.40 GHz.

This device can be used in different RF/Microwave system and subsystem. The high output power level, high efficiency and wide operating temperature range can make application very flexible.

Absolute Maximum Ratings (Tc=25°C)

Parameter	Symbol	Value	Unit
Drain-Source Voltage	VDS	40	V
Gate-Source Voltage	Vgs	-5	V
Storage Temperature	Tstg	-65 ~ +150	C°
Channel Temperature	Tch	150	٦°

*Not recommended to work under these conditions.

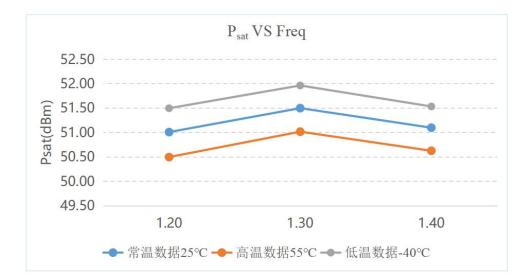
Microwave Electrical Characteristics

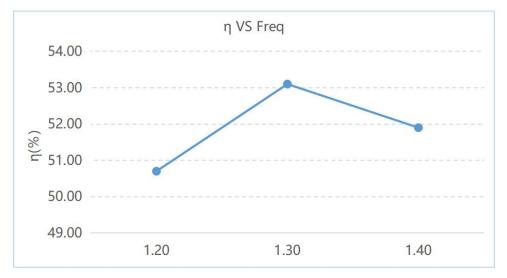
Parameter	Symbol	Test Condition	Min	Тур	Max	Unit
Drain Current	ldsr	VDS:32V CW Pin: 38dBm Freq: 1.2~1.4GHZ	-	7.9	-	А
Saturated Output Power	Psat		51	-	-	dBm
Power Gain	Gp		13	-	-	dB
Work Efficiency	η		50	-	-	%
Gain Flatness	ΔG		-0.8	-	0.8	dB

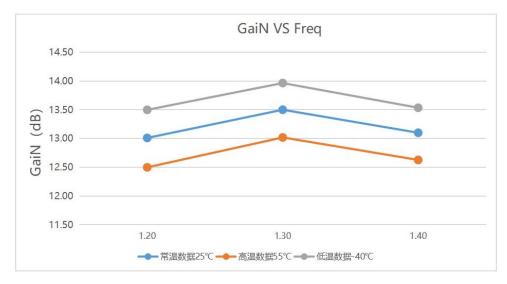


MCNI1214-P51 L-Band Internally Matched GaN Device

Typical Curves

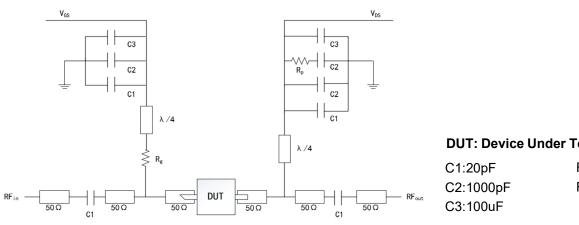








Recommended Application Circuit

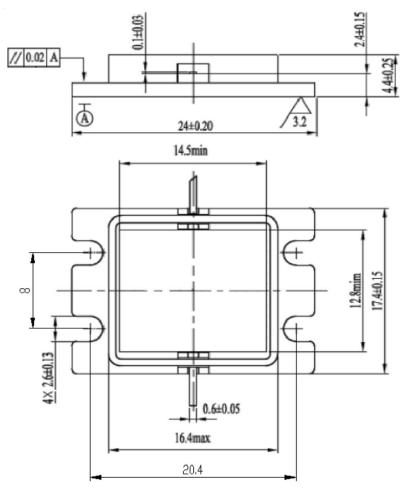


DUT: Device Under Test Rp:51Ω Rg:15Ω

ESD Level

ESD	Class III	2000V
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Overall Dimensions



Using Notes:

• During transportation and storage, ensure proper drying.

• During the use and assembly of the chip, take precautions against static electricity. Wear a grounded anti-static wristband.

· When powering on, apply gate voltage first, then apply leakage voltage.